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Quantum Hall effect in graphene decorated with disordered multilayer patches

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Quantum Hall effect (QHE) is observed in graphene grown by chemical vapour deposition using platinum catalyst. The QHE is even seen in samples which are irregularly decorated with disordered multilayer graphene patches and have very low mobility (<500 cm²V⁻¹s⁻¹). The effect does not seem to depend on electronic mobility and uniformity of the resulting material, which indicates the robustness of QHE in graphene. © 2013 AIP Publishing LLC.

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The integer quantum Hall effect (QHE) is a hallmark of a two-dimensional (2D) electron gas formed at the interface between semiconductors or their surfaces.1 Graphene is a two-dimensional (2D) electron gas formed at the interface between semiconductors or their surfaces.1 Graphene shows a half-integer QHE due to a Berry’s phase.2 The half-integer QHE in graphene demonstrates not only the 2D nature of graphene but also its unique Dirac-like electronic structure associated with the spin- and valley-degeneracy and the feature of the central Landau level (LL) like electronic structure associated with the spin- and valley-degeneracy and the feature of the central Landau level (LL)

Accordingly, most of the previous QHE experiments on graphene were performed using mechanically exfoliated graphene with high mobility exceeding 10⁴ cm²V⁻¹s⁻¹.3–7 However, there have been some reports on QHE in graphene grown by chemical vapour deposition (CVD) using nickel,11 and copper-catalyst.12 Although the QHE in the CVD-graphene was not as clear as in exfoliated one, the relatively high mobility of such a graphene (>3000 cm²V⁻¹s⁻¹) ensures seeing QHE. Recently, CVD-graphene on Pt was also grown and investigated,13–15 although no QHE in such a graphene has so far been reported in the literature. Graphene grown on Pt can have millimetre-sized hexagonal single-crystal grains and mobility greater than 7000 cm²V⁻¹s⁻¹ (Ref. 14), promising clear QHE in such samples.

Here, we experimentally confirm the half-integer QHE in CVD-graphene grown on platinum in the magnetic field B > 11 T. Surprisingly, we observe the QHE even in samples which are irregularly decorated with disordered multilayer graphene patches (see Fig. 1(a)) and have very low mobility (<500 cm²V⁻¹s⁻¹). This emphasizes the robustness of QHE in Pt-CVD graphene.

The graphene is synthesised in a cold-wall low-pressure CVD system16 equipped with a small-mass graphite heater. A 100 μm-thick polycrystalline Pt foil (99.99%) is employed as catalyst. First, we ramp up the temperature of the foil to 1000 °C at 300 °C/min and hold it at this temperature for 5 min in a flow of 1000 sccm H₂. Then, 70 scm CH₄ pre-diluted with Ar to 5% is introduced into the chamber to activate graphene growth. The growth time is 10 min. Finally, the foil is cooled down to below 100 °C within 15 min by turning off the heater current. The CH₄ is kept flowing while cooling down. We note that the growth temperature of 1000 °C is the nominal temperature obtained from a
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thermocouple sensor gently touching the heater. The actual catalyst temperature can be 100–200 °C higher. The high melting point (~1770°C) of Pt enables us to access high temperature over 1000°C, which is impossible to achieve with conventional Cu catalyst. In addition to the high temperature >1000°C, we use a low partial pressure of the precursor gas, different from the previous graphene growth on Pt, performed under atmospheric pressure and temperature ~1000°C.

We notice that changing the flow rate of CH₄ to somewhat in excess of ~50 sccm gives rise to additional multilayer graphene patches of ~5 μm in size (Fig. 1(a)), whereas the overflow of CH₄ (>100 sccm) generates much thicker and larger multilayer patches. This means that the thickness and size of the patches are controllable by the flow rate of CH₄.

Afterwards, the graphene is transferred onto a highly doped Si substrate capped with 300 nm SiO₂, allowing for a field-effect transistor structure. We employ the frame-assisted bubbling transfer technique instead of usual wet etching of the metal catalyst thereby avoiding etching residues and possible damage of graphene caused by strong acids as in the case of Pt catalyst. The semi-rigid frame supporting the PMMA coated graphene allows for easy handling and cleaning of graphene. Using the frame, we can rinse graphene more thoroughly during the transfer process. Finally, graphene Hall bar structures (~10 × 40 μm²) are patterned using a standard micro fabrication process.

The resistance measurements are carried out using a current-reversing dc technique with a bias current of 100 nA. In addition, the measurements are done both at positive and negative magnetic fields to be able to eventually compensate for a small misalignment of the Hall contacts.

Fig. 1(a) shows an optical image of our graphene sample placed on the SiO₂/Si substrate. The image contrast is sufficient to discern the boundary of graphene and its inhomogeneous structure. We can see that relatively dark patches (~5 μm) are scattered all over the sample. The patchy structure is made by increasing the flow rate of CH₄ to about 70 sccm during the growth process compared to the optimal flow rate of CH₄ ~50 sccm for growing a single-layer graphene without patches. If we further increased the flow rate of CH₄, much thicker pyramid-like patches would be formed, where several graphene layers would be clearly distinguishable.

We measure the 4-probe conductance of graphene at different charge carrier densities by tuning the gate voltage at the temperature T = 100, 10, and 2 K (see Fig. 1(b)). The conductance curves show a p-type doping (Dirac point V_DK ~ +6.5 V); their shape is independent of the voltage-contact pairs (1 and 2 or 3 and 4 in Fig. 1(a)). Thus, the patches do not appear to affect the overall average conductance of the sample. The conductance has a positive temperature dependence (dG/dT > 0) in the whole range of the gate voltage. This agrees with the previous results on defective graphene deliberately damaged by the hydrogenation or ion irradiation. The positive temperature dependence in our case can also be associated with the inhomogeneity of our sample and explained by the heterogeneous model of variable-range hopping where well conducting regions (single layer graphene) are separated by less conducting regions (multilayer patches).

The slope of conductance curves allows for rough estimates of the mobility at different temperatures (see the inset of Fig. 1(b)). In contrast to usually enhanced mobility of monolayer graphene at lower temperature, the mobility of this sample decreases with decreasing temperature, which results in the mobility μ ~400 and 190 cm²/V·s at T = 2 K for holes and electrons, respectively. The temperature dependence of mobility is analogous to that of multilayer graphene where Coulomb scattering is dominant and the substrate surface polar phonon induced electric field is screened by extra graphene layers. Hence, we believe that our positive temperature dependence of mobility can be associated with the multilayer patches in the sample. Here, we use a parallel-electrode capacitance model. The Hall mobility for the holes is ~310 cm²/V·s, which is comparable with the field-effect result. It is a very low mobility compared to the previously reported graphene field effect devices in literatures. The low mobility cannot be only attributed to the presence of the defective patches because the distance between them is rather big. Even in the predominantly single-layer areas (region A), the graphene is quite disordered as seen in the Raman spectra in Fig. 1(d).

In an effort to identify the patch composition, Raman spectroscopy is performed. Fig. 1(c) indicates mapping of Raman intensity ratio between 2D- and G-bands for graphene region enclosed by dashed line in Fig. 1(a). We find that the intensity ratio of graphene patches (blue round...
regions) is smaller than one. Fig. 1(d) shows Raman spectra from different sample parts denoted in Fig. 1(a): A (outside the patch) and B (at the patch). The spot A demonstrates a typical Raman spectrum characteristic for a disordered single layer graphene with exception for additional peaks between D and G bands. The peaks can be caused by amorphous (hydrogenated) carbon formed during sample growth or device fabrication. The Raman spectrum in region B displays a much stronger intensity of both D-band (related to the inter-valley scattering process) and D´-band (associated with the intra-valley scattering process in graphene) compared to that of the single layer region A. This indicates that graphene is much more disordered in patch spot B than in single-layer area A. In addition, the spectrum obtained from the patch shows a broader 2D-band accompanied with blue shift (≈-7.1 cm⁻¹) and lower ratio of I₂D to I_G. This is consistent with the signature of multi-layer graphene. Therefore, we conclude that the dark patches consist of a defective multi-layer graphene.

We now turn to QHE measurements. In general, it is known that single-layer graphene shows the half-integer QHE conductance plateaus \( \sigma_{xy} = \pm 4(n + 1/2)e^2/h \) with the non-negative integer \( n \) and filling factors \( \nu = 2, \pm 6, \pm 10, \ldots \). The integer step of 4 in \( \nu \) is a manifestation of the four-fold degeneracy of graphene LL owing to the spin-valley degeneracy. Occasionally, high quality graphene shows other integer \( \nu \) owing to symmetry breaking, even fractional \( \nu \) can sometimes be found. Figs. 2(a) and 2(b) show the longitudinal resistance \( R_{xx} \) and Hall resistance \( R_{xy} \) as a function of the gate voltage measured at the magnetic field \( B = 14 \text{T} \) and \( T = 2 \text{K} \). We can see that the longitudinal resistance \( R_{xx} \) abruptly drops to nearly zero (160 Ω and 530 Ω for holes and electrons) whereas \( R_{xy} \) reaches the quantum Hall plateaus at \( \nu = \pm 2 \) corresponding to \( \approx \pm 12.9 \text{kΩ} \). The slight deviation of the measured values (≈12.5 kΩ and \( \pm 12.3 \text{kΩ} \) for holes and electrons) from the exact QHE plateau value is caused by the external shunting resistors of 1 MΩ connecting all the electrodes together to avoid occasional sample damage due to discharges. The deviation can also be a result of incompletion of the quantum Hall state in our system as indicated by the non-zero \( R_{xx} \). The presence of bilayer regions can be the cause of such a situation. Besides, a weak signature of the plateaus at \( \nu = \pm 6 \) (≈4.30 kΩ) can be found together with a slight dip in \( R_{xx} \). The higher-order plateaus cannot be seen much likely due to disorder-induced broadening of the LLs at higher energy. The QHE is seen more clearly on the hole side due to the higher mobility of holes (400 cm²V⁻¹s⁻¹) compared to the mobility of electrons (190 cm²V⁻¹s⁻¹).

Evolution of the quantum Hall plateaus with magnetic field is shown in Fig. 2(c). For comparison, we prepare a uniform monolayer (non-patched) Pt-CVD graphene using reduced flow rate of CH₄≈50 sccm. The sample shows a relatively high mobility \( \mu \approx 2000 \text{cm}^2\text{V}^{-1}\text{s}^{-1} \); its QHE is denoted as dashed red line. The QHE measurements for both patched (low mobility)- and non-patched (high mobility)-- samples are conducted at the fixed gate voltages \( V_g \) corresponding to the first dip position on the hole-side of the \( R_{xx}(V_g) \) curves. Here, the two different slopes of \( R_{xy} \) in the low \( B \)-field regime (\( B < 4 \text{T} \) represent different carried densities. According to the inset showing the zoomed-region, we find that \( R_{xy} \) in our patched graphene starts saturating to quantum Hall plateau from \( B \approx 11 \text{T} \), while non-patched graphene converges to it from \( B = 10 \text{T} \). The variation of plateau values between the two cases is much likely due to different contact resistances in each measurement. Indeed, the part of the current that branches off into the shunt resistors depends on the contact resistances rather than the quality of graphene.

It is interesting that QHE is developed even in such low mobility CVD-graphene where highly defective multilayer graphene patches are dispersed. Although there are reports on QHE in CVD-graphene grown on Ni²⁺ and Cu, the graphene mobility is usually larger than 3000 cm²V⁻¹s⁻¹ associated with less defects (also witnessed by a small Raman D-band). According to the Raman spectra in Fig. 1(d), the mobility of graphene in the single layer region can be estimated to be \( \approx 3000 \text{cm}^2\text{V}^{-1}\text{s}^{-1} \). In principle, the mobility is high enough to validate the QHE so that our observation of QHE in the (on average) low-mobility sample can be ascribed to the locally high mobility graphene. This is in agreement with in general higher quality of CVD-graphene grown on Pt.

Indeed, recent study shows that graphene grown on Pt can have millimetre-sized hexagonal single-crystal grains with mobility greater than 7100 cm²V⁻¹s⁻¹, which implies superior graphene quality compared to previously reported CVD-graphene using other metal catalysts. Additionally, we use the bubbling transfer technique instead of wet etching. This technique allows avoiding etchant residues and getting cleaner graphene surface. Therefore, Pt catalyst combined with bubbling transfer can be favourable for QHE behaviour.

Based on the measurements of \( R_{xx} \) and \( R_{xy} \) in Figs. 2(a) and 2(b), we show the longitudinal \( (\sigma_{xx}) \) and Hall \( (\sigma_{xy}) \) conductivities in Fig. 3 as functions of the carrier density \( n = \beta(V_g - V_{DP}) \), where \( \beta \approx 6.7 \times 10^{10} \text{cm}^2\text{V}^{-1} \), obtained.
from Hall measurement) measured in units of 2eB/h which correspond to the half of filling factor ν/2 (ℏ/2eB). Here, ħ and e are the Planck’s constant and electron charge, respectively. Apart from the expected quantum Hall conductivity plateaus at ±2e2/ħh, we see other features. First, at the Dirac point (n = 0), σxy shows an unexpected dip while σxx has an unusual Hall plateau as indicated by the two vertical blue arrows in Fig. 3. This can be attributed to a band gap formation at the Dirac point resulting in a slight splitting of the central LL at n = 0 into two levels. Until now, the ν = 0 quantum Hall state has been experimentally observed only for high quality graphene made by mechanical exfoliation. This state is normally explained by the spin-valley symmetry breaking which lifts the degeneracy of LL, counter-propagating edge states, and gap opening in the magnetic field. We believe that in our case it is rather due to the disorder induced gap opening resulting from the defective multilayer graphene patches. In fact, we also observed the same behaviour of the QHE in wrinkled CVD-graphene grown on Cu (not shown here).

Moreover, the centre of the dip (in σxx) and plateau (in σyy) is somewhat shifted from the anticipated positions ν = ±2 denoted by the vertical dashed lines. This can be attributed to a pool of localized states which do not contribute to the degeneracy of LL. The localized states are situated between LLs and result in a “delay” when filling LLs by increasing carrier density. Here, the spatially distributed graphene patches probably act as origin of the localized states.

We have observed the QHE in CVD-graphene grown on platinum. The QHE is even seen in samples which are irregularly decorated with disordered multilayer graphene patches and have very low mobility (< 500 cm2V−1s−1). The effect does not seem to depend on electronic mobility and uniformity of the resulting material, which indicates the robustness of QHE in graphene.

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17 For instance, the nominal value corresponding to Cu melting point is about 850°C. Therefore, we believe actual temperature in the case of Pt catalyzed is also somewhat higher than 1000°C.